

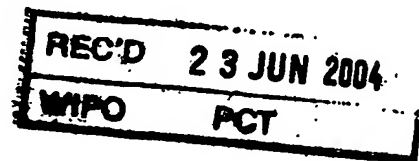


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03076725.5

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Anmeldung Nr:
Application no.: 03076725.5
Demande no:

Anmeldetag:
Date of filing: 03.06.03
Date de dépôt:

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Low pass filter and electronic device

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Low pass filter and electronic device

The invention relates to a low pass filter comprising a large and a small capacitor that are connected in parallel, the large capacitor being connected in series with a resistor.

The invention also relates to an electronic device provided with a phase locked loop function comprising a comparator, a low pass filter and a voltage controlled oscillator, the comparator
5 and the oscillator being part of a single semiconductor device and the low pass filter being embodied with a small and a large capacitor.

- Such an electronic device is commercially available as a Bluetooth module provided by Philips Semiconductors as BGB101A. Such Bluetooth module comprises all high frequency
10 elements needed for the operation according to the Bluetooth protocol, including a transceiver, a power amplifier for amplifying the output signal to an antenna, a low noise amplifier for amplifying an input signal from the antenna as well as necessary switches, matching functions and filters. The antenna may be part of the module, but can be provided separately as well.
- 15 The low pass filter in this module is embodied with discrete capacitors and a discrete resistor. The small capacitor has a value of 2.2 nH and the large capacitor has a value of 22 nH. The filter forms a phase locked loop (PLL)- function together with the comparator and the oscillator. In the device, the loop gets an input signal at the comparator. This compares the input signal to a reference signal from the oscillator and sends its output to the low pass filter.
- 20 The output of the low pass filter is used both as output signal and as input for the oscillator. The output of the oscillator is the reference signal used by the comparator. The low pass filter has two functions in this topology: it is a filter rejecting all high frequency components. Moreover, it will assure that the frequency of the oscillator is maintained, when the device is in the sending mode. Hereto, it is of importance that the capacitors are able to
25 keep the specified frequency. In order thereto, capacitors that fulfill the NPO-standard are used in the known module. This standard prescribes that the capacitance varies less than 30 ppm/°C over a temperature range between -30 and +85 °C.

It is a disadvantage of the current solution that these capacitors are relatively large. It is desired to reduce the space of the module, so that it can be included more easily in all kinds of hand-held apparatus.

- 5 It is therefor a first object to provide a low pass filter of the kind described in the opening paragraph with a reduced size.

It is a second object of the invention to provide an electronic device with the improved pass filter.

- 10 The first object is achieved in that the filter is embodied on the basis of a semiconductor substrate with a first surface, in which the small and the large capacitor are provided as vertical trench capacitors, the trenches extending to the first surface, at which the resistor is provided. Experiments have shown that the drift of the low pass filter according to the invention is within the specifications, both at -30°C , at room temperature and at $+85^{\circ}\text{C}$. This
15 enables the use of the filter in a so-called open loop architecture.

- Vertical trench capacitors are known per se, for instance from Roozeboom et al, *Int.J. Microcircuits and Electronic Packaging*, 24(2001), 182-196. There is however no teaching or suggestion that capacitors with different capacitances can be integrated in a single substrate together with desired resistors. It is not known either that in such a single substrate
20 the leakage of the capacitors and the temperature stability is according to specifications.

- In a preferred embodiment the semiconductor substrate further comprises a drift compensation part. Such a drift compensation part is suitably embodied as an RC-filter that is coupled to ground. It is connected in parallel to the filter. This may be embodied in that there is a separate connection — i.e. solder ball or bond wire — from the drift
25 compensation part to the semiconductor device. The RC-filter is chosen such as to have the same period (time constant), as the drift which occurs in the open loop architecture. The combination of low pass band filter and drift compensation part takes away the disadvantages of open loop modulation, in that no more expensive discrete capacitors are needed. It furthermore has the advantage of an open-loop modulation that a very pure signal
30 is provided without any spurious components as necessary in a closed-loop architecture. In a further embodiment the filter is connected to ground at one end. This is an embodiment of the open loop architecture. It is preferred that both the drift compensation part and the filter are connected to ground, such that there is one connection to ground from the pass filter.

It is preferred that the small and the large capacitor are separated through a high-ohmic substrate zone with a resistance of at least 0.5 k Ω /cm. Herewith the leakage current can be reduced as desired. Preferably the substrate zone has a resistance of about 1.0 k Ω /cm. The substrate resistance is preferably increased by implantation, more preferably by
5 implantation with Ar gas.

In another embodiment, the trench capacitors have a dielectric comprising silicon nitride. Such a dielectric does not show any hysteresis. It has been found preferable to use a stack of silicon oxide, silicon nitride and silicon oxide as the dielectric. Such stacks turn out to have excellent breakdown voltages.

10 In a further embodiment the resistor comprises a layer of polysilicon, in which layer the upper electrodes of the capacitors are defined as well. This is advantageous in view of processing.

In an even further embodiment, the semiconductor substrate further comprises diodes. Such diodes can be suitably embodied as a pn diode, a Zener diode, a back-to-back
15 diode, a front-to-back diode or a floating diode. The diodes can be combined with the high-ohmic substrate very well, in that only part of the substrate is made high-ohmic. This is also preferable for the etching of the vertical trench capacitors. The advantages of the integration of the diodes are at least twofold. First, the open loop architecture can be embodied in that the low pass band filter and the drift compensation part are each connected to diodes. A
20 larger part of the phase locked looped function can thus be integrated in the semiconductor substrate. This allows that the number of connections between the filter and the semiconductor device is reduced. It furthermore allows that the available space is used more efficiently, and hence may lead to miniaturisation of the electronic device. A second advantage is that the semiconductor device can thus be more specifically designed for its
25 functions of comparator and oscillator. It is for instance possible to use other substrate materials, in which the diodes do not fit well.

The second object of the invention is achieved in that the low pass filter according to Claim 1
30 is present, which is filter is assembled to the semiconductor device in a stacked die construction. Due to the stacked die construction, the space for the discrete capacitors is not needed anymore. Surprisingly, it was found therewith that the presence of the filter on top of the semiconductor device does not influence any inductors implented therein.

In a suitable embodiment the semiconductor device is provided with a first and an opposed second side, at which first side the low pass filter is present and at which second side the

semiconductor device can be coupled to a heat sink. The semiconductor device must dissipate more heat than the pass filter, and should thus be provided with a heat sink. This can be realized in two different manners; first of all, in that the semiconductor device is attached with its second side to a heat sink on a carrier, or on a leadframe. The filter is then provided
5 as a component on the first side of the semiconductor device. The second embodiment is that the device is provided with a leadframe to which the semiconductor device is attached. The filter can then act as a support for the semiconductor device, and its surface can be provided with interconnects that are used for rerouting.

In a preferred embodiment the low pass filter has lateral dimensions which are
10 at most equal to that of the semiconductor device. In this embodiment, the low pass filter will be a component on top of the semiconductor device. The connections between the filter and the semiconductor device can be realized both with wirebonding and with solder or metal bumps. In case bumps are used, the semiconductor device is preferably provided with bond pads on active. Such presence of bond pads on top of areas in which transistors are defined
15 requires a stabilisation of the interconnect structure of the semiconductor device. For instance, it can be that the bond pads are provided as conducting tracks on top of the passivation layer. The use of bond pads on active allows that the filter can be positioned on any location at the first side of the semiconductor device. It is preferred that the device is encapsulated after that the filter is assembled to the semiconductor device.

20

These and other aspects of the filter and the electronic devices of the invention will be further explained with reference to the figures, in which:

Fig. 1 shows a diagrammatical cross-section of a first embodiment of the device;

25

Fig. 2 shows a diagrammatical cross-section of a second embodiment of the device;

Fig. 3 shows a diagrammatical top-view of the second embodiment

Fig. 4 shows an electrical diagram corresponding to the invention

Fig. 5 shows a birds' eye perspective on a prototype of the filter of the

30

invention;

Fig. 6 shows a schematical drawing of an application of the present device.

The figures are not drawn to scale and like reference numbers refer to like parts.

Fig. 1 shows a first embodiment of the electronic device 100 of the invention. It comprises the low-pass filter 20 and the semiconductor device 30. The semiconductor device comprises not-shown electrical functions, which generally include a transceiver and an oscillator. However, the semiconductor device 30 can be limited to an oscillator and a comparator only.

5 The semiconductor device 30 is provided on a heat sink 13 with a layer of electrically conducting glue or solder. It is electrically connected to the filter 20 with metal bumps 24. The filter 20 herein also acts as a carrier and comprises any interconnects that are necessary for rerouting purposes. Finally, it comprises the contacts to the leadframe 10 through solder bumps 27. The leadframe 10 shown here is a leadframe of the HVQFN-type (High Voltage
10 Quad Flat Non-Leaded) having a first side 11 to which the filter 20 and the semiconductor device 30 are attached. It further has a second side 12, at which the contacts 16, 17 and the heatsink 13 are exposed. The leadframe is half-etched from the second side 12, leading to spaces 18, which are filled with encapsulating, electrically insulating material and being part of the encapsulation 80.

15 Fig. 2 and 3 show a second, preferred embodiment of the electronic device 100 or the invention. Fig. 2 shows a diagrammatical cross-sectional view and Fig. 3 shows a top view. According to this embodiment, the filter 20 is positioned on top of the semiconductor device 30 and is attached thereto with a layer of non-conductive adhesive 26. The semiconductor device is also in this case provided on a heatsink 13, that is part of a leadframe
20 10. In this embodiment, the heatsink 13 also acts as a ground plane. The electrical connections between the filter 20, the semiconductor device 30 and the leadframe 10 are realized with wirebonds 31-34. Wirebonds 31 connect the filter 20 with the semiconductor device 30. Wirebonds 32 connect the semiconductor device 30 to the contact 17 at the leadframe 10. These connections 31,32 are signal carrying. The wirebonds 33,34 are
25 connections to the ground 16. Although wirebonds are preferable in view of the ease of application, a flip-chipped connection with metal/or solder balls, or a connection wherein both wirebonding and flip chip are used, can be used alternatively. The connection 33 to ground from the filter 20 is particularly suitable for an open-loop architecture. It is understood that the specific lateral position of the filter on the semiconductor device 30 is a
30 matter of implementation.

Fig.4 shows an electrical schema that is used in the preferred embodiment. In this embodiment, the filter does not only comprise a small capacitor C1 and a large capacitor C2, which is connected in series with a resistor R1, but also a drift compensation part. This drift compensation part comprises a capacitor C3 and a resistor R2. The small capacitor C1 has a

value of 2.2 nH and the large capacitor C2 has a capacitance of 22 nH. The capacitor C3 has a value of 5.6 nH. These values are used for an oscillator that acts at the frequency of the Bluetooth protocol, that is 2.4 GHz. It will be clear that for other frequency bands other capacitances can be chosen. Furthermore, in the present example, the filter is designed to operate at a single frequency only. It can be extended however to include the elements for more frequency bands as well.

Fig. 4 furthermore shows the coupling of the drift compensation part and the filter to the circuitry. At the one end, both the filter and the compensation part are coupled to ground. This is embodied in the example shown in Fig. 2 and 3 in a combined connection to the ground. At the same time, the drift compensation part and the filter are connected in parallel. Each of them is therewith present between diodes. The circuit part is furthermore provided with resistors R3 and R3'. The diodes and the resistors can be integrated in the filter 20 if so desired.

Experiments show that the present filter has the desired properties to act as a low pass band filter. The experiments have been done at different temperatures, at different frequencies and for hopping modes at different frequencies, and at different tuning voltages.

Frequency GHz	temperature	2.402	2.441	2.478
DH1(KHz)	25 °C	-17	-16	-18
DH5(KHz)	25 °C	-29	-26	-30

20 If the frequency is set to hopping mode , an average drift of -15KHz for DH1 and -26KHz for DH5 is found.

Frequency GHz	temperature	2.402	2.441	2.478
DH1(KHz)	85 °C	-10	-19	-19
DH5(KHz)	85 °C	26	-25	-32

25 In the hopping mode an average drift of -12KHz for DH1 and -25KHz for DH5 is observed.

Frequency GHz	temperature	2.402	2.441	2.478
DH1(KHz)	-30 °C	15	13	15
DH5(KHz)	-30 °C	40	17	-28

In the hopping mode of frequency an average drift is found of 19 kHz for DH1 and 42 KHz for DH5. An optimal value can be achieved by tuning the transceiver.

5

Further measurement were done at a static environment in order to check the level of the tuning voltage V_{tune} . This was done in view thereof that the semiconductor device 30 comprises a coil, and the filter 20 is present on top thereof. The coil is used in the voltage controlled oscillator.

10 At a tuning voltage level V_{tune} of 3Volt and of 2.7 Volt the following was observed:

Frequency GHz	2.402	2.441	2.478
Vtune(V)	1.4	1.64	1.94
DH5(KHz)	-25	-20	-16

As is clear hereof, the differences of the tuning voltage level do not affect the data found. It thus can be concluded that the tune voltage is not effected by the specific location of the filter

15 20 on top of the semiconductor device 20.

Fig. 5 shows a bird's eye perspective on a prototype of the filter of the invention. In fact, the shown prototype is an array of trench capacitors. These capacitors are provided in a semiconductor substrate 1 of Si. The lower electrode 2 comprises a n^+ doped zone in the substrate 1. Thereon a dielectric 3, actually of silicon nitride, is provided. The top electrode 4 is realized in polysilicon, that is n^+ -doped. On top thereof a metal layer is provided in which the contacts for the top electrode 5 and for the lower electrode 6 are defined. The pores in the substrate 1 have a diameter in the order of 1 μm and a depth of about 20 μm . The capacitance of the capacitors is defined by the number of pores. Between the capacitors the substrate is made high-ohmic. This provides a barrier between leakage between the individual capacitors C1, C2, C3. If desired, resistors can be defined at the substrate surface, for instance in the

same layer of polysilicon in which the top electrode 4 is defined. If desired, planar capacitors can be defined at the substrate surface. If desired, inductors can be defined in the metal layer used for the contacts 5,6. The pores can be grown with dry etching or with wet-chemical etching, such as known from Roozeboom et al., *Int. Journal of Microcircuits and Electronic*
5 *Packaging*, 24(2001), 182-196.

Fig.6 shows the architecture of an application of the electronic device 100 of the invention. In fact, this application is a front-end radio module 200 suitable for processing signals according to the Bluetooth protocol. The module 200 comprises the semiconductor device 30 and the
10 filter 20. The semiconductor device 30 contains in this case both the voltage controlled oscillator and the transceiver and the power and low noise amplifier (shown as triangles in the figure). The transceiver part comprises the functions of the regulator 211, the control logic 212, the synthesizer 213, the DC extractor 214 and the demodulator 215. In addition to the semiconductor device 30 and the filter, the module 200 comprises a supply decoupling
15 205, with as input the supply voltages and the ground. The module 200 further comprises a transmit path in which a balun and filter 203 is present; a receive path in which a balun and filter 204 is present; a switch 202 between the transmittal and the receival paths, and a band pass filter 201.

CLAIMS:

- 5 1. A low pass band filter comprising a large and a small capacitor that are connected in parallel, the large capacitor being connected in series with a resistor, characterized in that the filter is embodied on the basis of a semiconductor substrate with a first surface, in which the small and the large capacitor are provided as vertical trench capacitors, the trenches extending to the first surface, at which the resistor is provided.
- 10 2. A low pass band filter as claimed in Claim 1, characterized in that the semiconductor substrate further comprises a drift compensation part.
- 15 3. A low pass band filter as claimed in Claim 1, characterized in that the filter is with one end connected to ground.
- 20 4. A low pass filter as claimed in Claim 1, characterized in that the small and the large capacitor are separated through a high-ohmic substrate zone with a resistance of at least 0.5 k Ω /cm.
5. A low pass filter as claimed in Claim 1, characterized in that the trench capacitors have a dielectric comprising silicon nitride.
- 25 6. A low pass filter as claimed in Claim 1, characterized in that the resistor comprises a layer of polysilicon, in which layer the upper electrodes of the capacitors are defined as well.
7. A low pass filter as claimed in Claim 1, characterized in that the semiconductor substrate further comprises diodes
- 30 8. An electronic device provided with a phase locked loop function comprising a comparator, a low pass filter and a voltage controlled oscillator, the comparator and the oscillator being part of a single semiconductor device and the low pass filter being embodied with a small and a large capacitor, characterized in that the low pass filter according to any of the Claims 1 to

7 is present, which is filter is assembled to the semiconductor device in a stacked die construction.

5 9. An electronic device as claimed in Claim 8, wherein the semiconductor device is provided with a first and an opposed second side, at which first side the low pass filter is present and at which second side the semiconductor device can be coupled to a heat sink.

10 10. An electronic device as claimed in Claim 8 or 9, characterized in that the low pass filter has lateral dimensions which are at most equal to that of the semiconductor device.

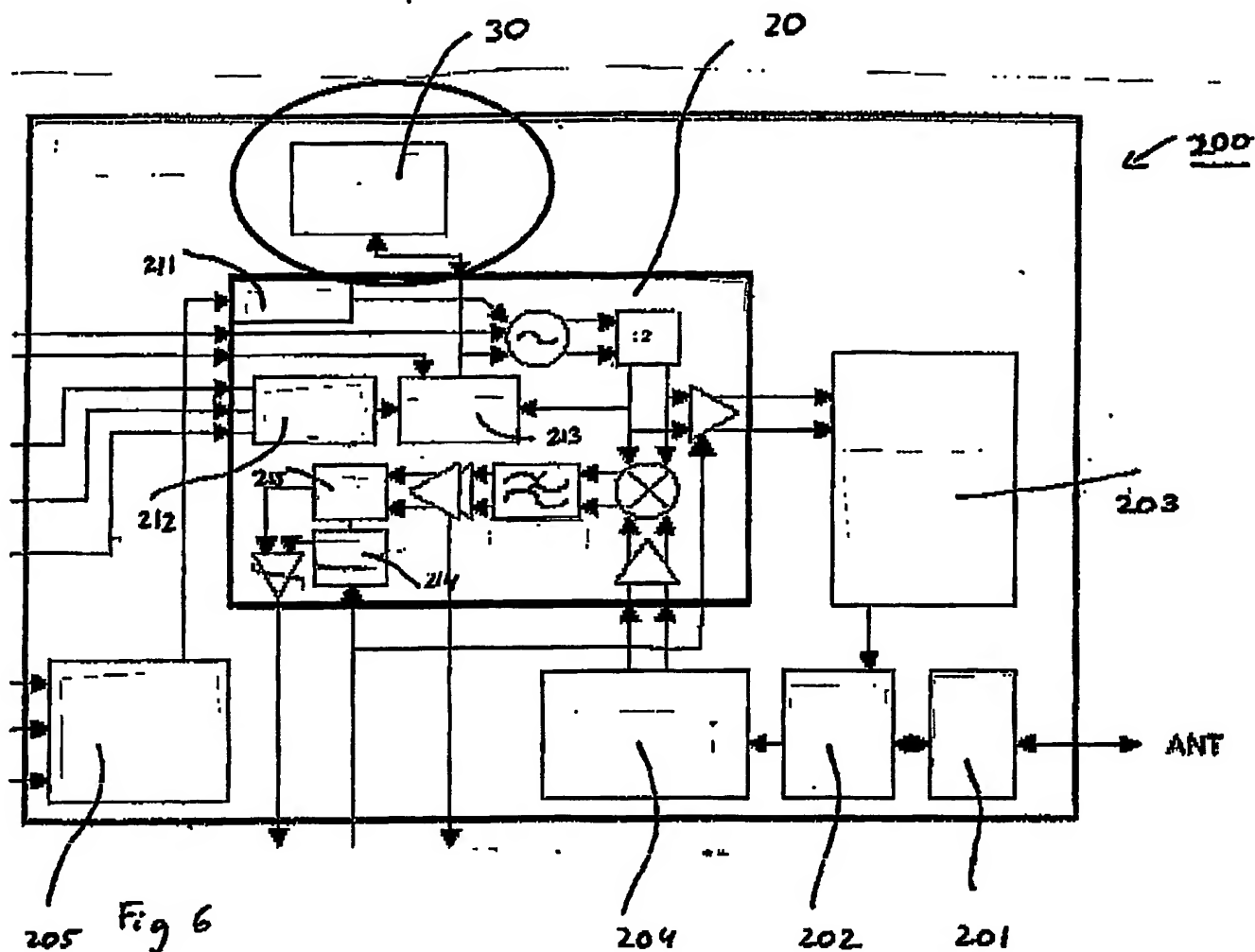
11. An electronic device as claimed in Claim 8, wherein the phase locked loop is provided in an open loop architecture.

ABSTRACT:

- 5 The electronic device (100) of the invention comprises a semiconductor device (30) and a low pass filter (20), which are present in a stacked configuration, and which together include a phase locked loop. The low pass filter is preferably embodied with vertical trench capacitors, and preferably comprises a drift compensation part. The device (100) can be suitably provided in an open-loop architecture.

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Fig. 2



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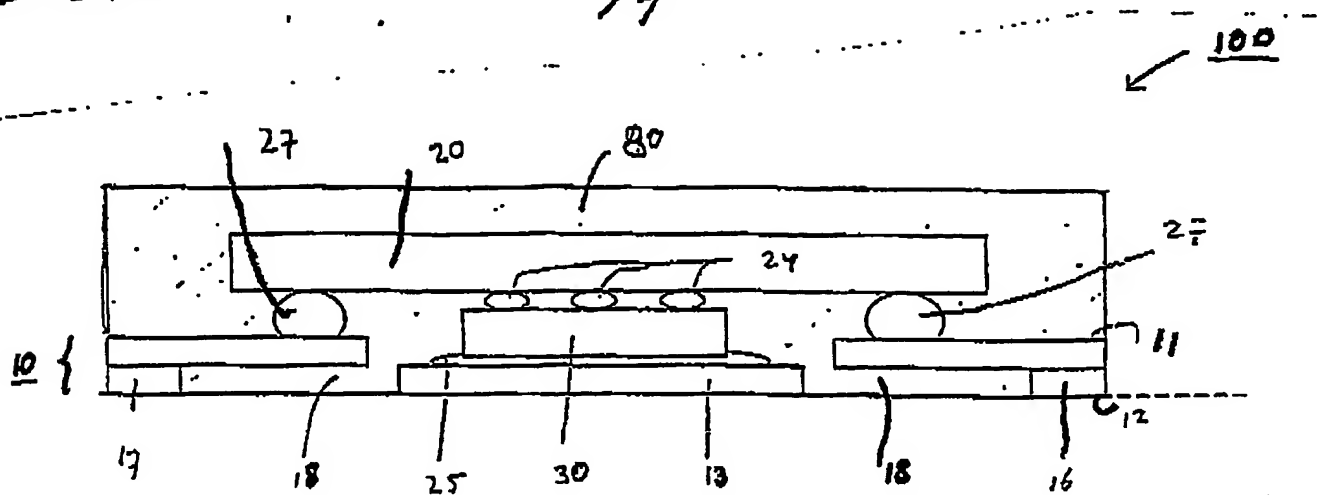


Fig 1.

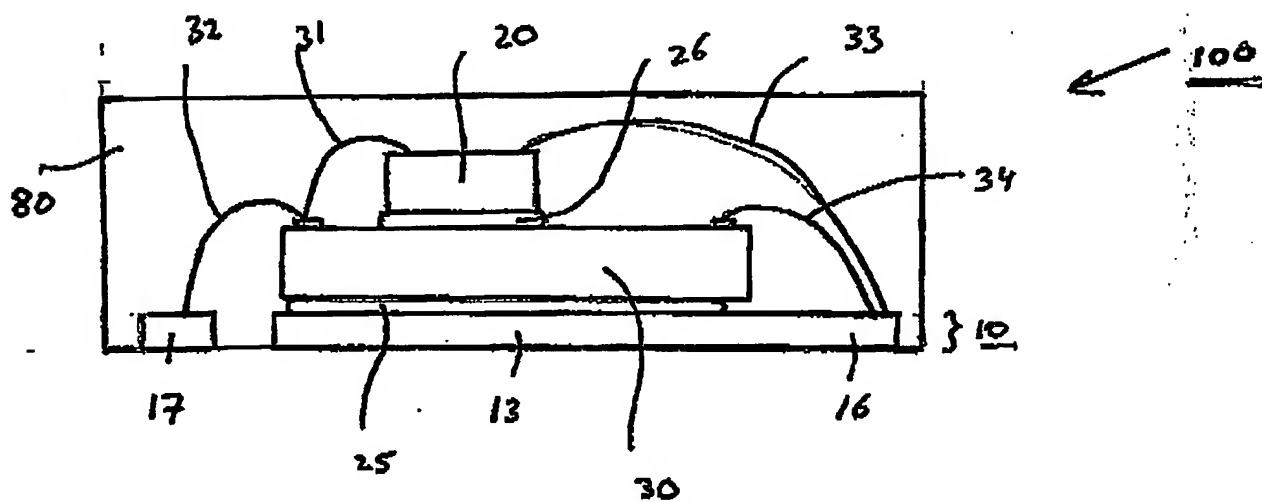


Fig 2.

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Fig 3

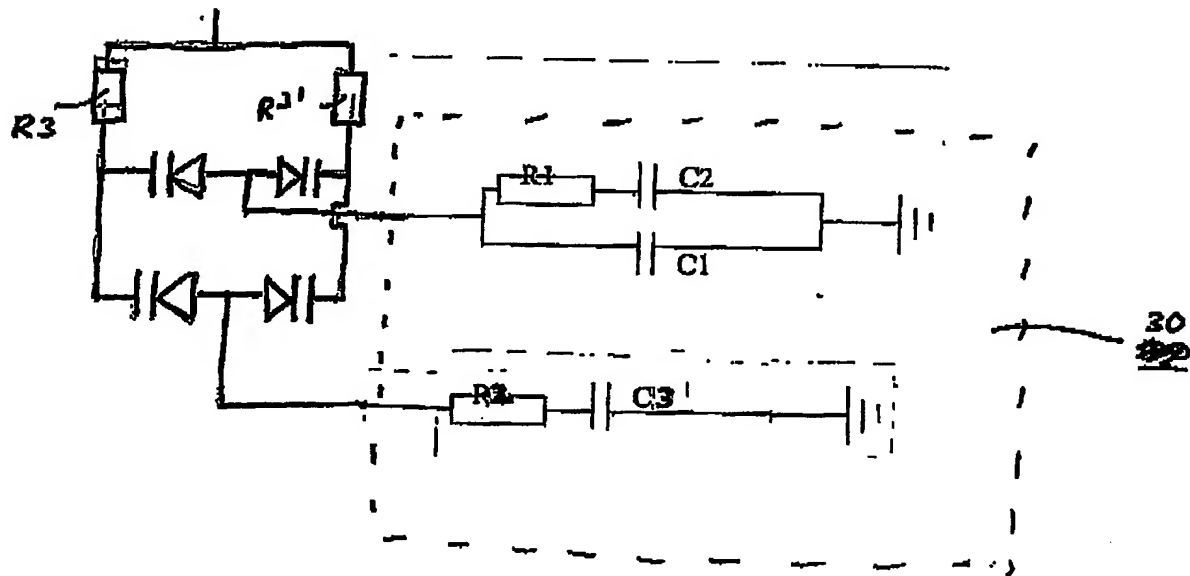
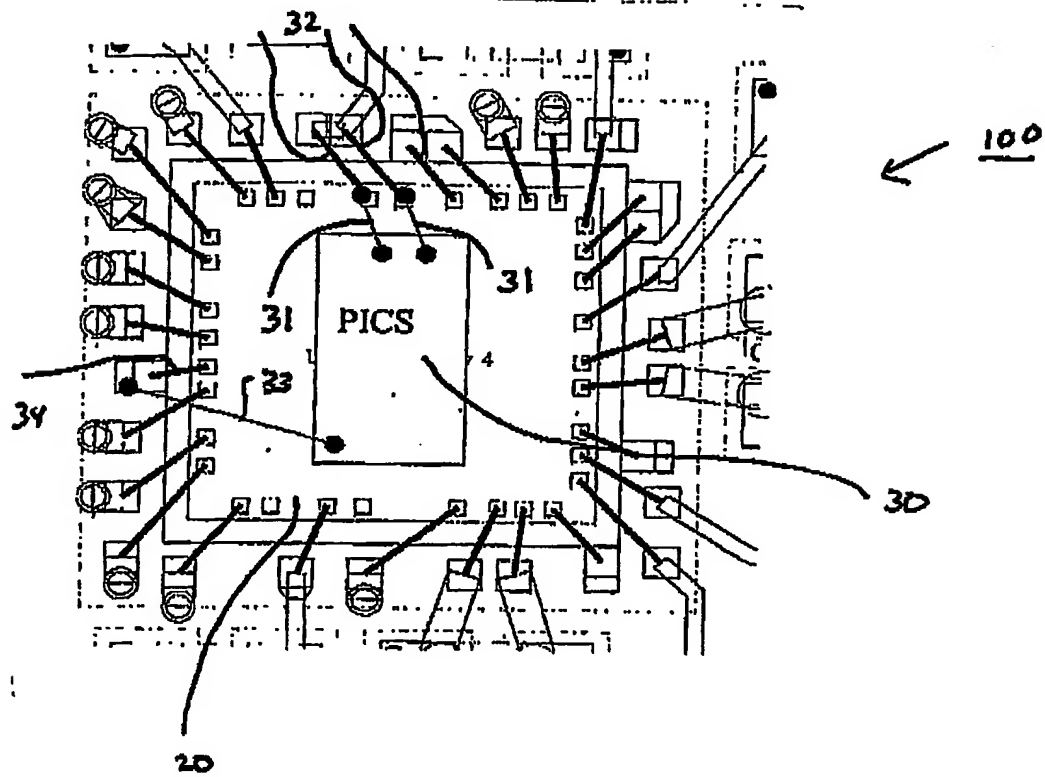


Fig 4

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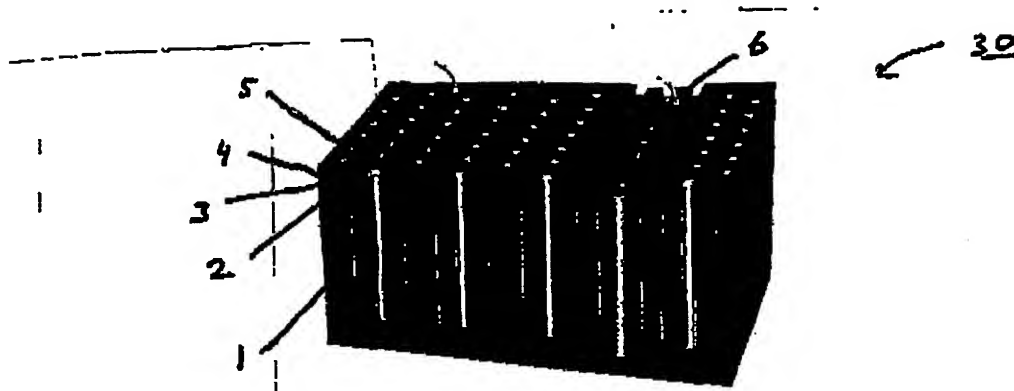


Fig. 5

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